Electronic Acknowledgement Receipt				
EFS ID:	1085139			
Application Number:	10808692			
Confirmation Number:	6062			
Title of Invention:	Composition for forming porous film, porous film and method for forr the same, interlevel insulator film and semiconductor device			
First Named Inventor:	Tsutomu Ogihara			
Customer Number:	826			
Filer:	Tyler Spence/Sarah Simmons			
Filer Authorized By:	Tyler Spence			
Attorney Docket Number:	035576/276101			
Receipt Date:	20-JUN-2006			
Filing Date:	25-MAR-2004			
Time Stamp:	16:03:34			
Application Type:	Utility			
International Application Number:				
Dovment information.				

Payment information:

Submitted with Payment	no
------------------------	----

File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages
1		276101ReplyAfterFinal.PDF	165838	yes	4

	Multipart Description			
	Doc Desc	Start	End	
	Amendment After Final	1	1	
	Applicant Arguments/Remarks Made in an Amendment	2	4	
Warnings:			'	

Information:

Total Files Size (in bytes): 165838

This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.

New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.